

Erratum to: Enhancement of silicon nanowire opto-electric properties by combining acid vapor etching and lithium pore-filling

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The original version of this article unfortunately contained mistakes in the author name and the affiliation.

1. The third author's name should be read as "Abderrahmane Hamdi" instead of "Abderrahamn Hamdi"
2. The affiliation of the first and third author should read as: Chohdi Amri 1,3* and Abderrahmane Hamdi 1,3

The online version of the original article can be found under
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